

Form PTO-1449 U.S. Dept. of Commerce Patent & Trademark Office List of Documents Cited by Applicant (Use several sheets if necessary)	Atty. Docket: YOR920000571US2 Serial No. Not Yet Assigned Applicant: Richard A. HAIGHT et al. Filing Date: HEREWITH
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U.S. PATENT DOCUMENTS

Ex'rs In'l	Document Number	Date	Name	Class	Sub- class	Filing Date, if applicable
	AA1	6,090,507	Grenon et al.			
	AA2	5,246,745	Baum et al.			
	AA3	4,615,904	Ehrlich et al.			
	AA4	4,608,117	Ehrlich et al.			
	AA5	4,340,617	Deutsch et al.			
	AA6	5,753,320	Mikoshiba et al.			
	AA7	5,308,651	Ohta et al.			
	AA8	5,130,172	Hicks et al.			
	AA9	5,060,595	Ziv et al.			
	AB1	6,261,850	Marsh			
	AB2	6,312,768	Rode et al.			
	AB3	5,407,710	Baum et al.			
	AB4	5,686,206	Baum et al.			
	AB5	4,451,503	Blum et al.			
	AB6	4,769,310	Gugger et al.			
	AB7	4,711,790	Morishige			
	AB8	6,319,566	Polanyi et al.			

FOREIGN PATENT DOCUMENTS

Document Number	Date	Country	Class	Sub- class	Transl'n Yes/No
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OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

	AB9	R. Solanki et al, "Laser Photodeposition of Refractory Metals", App. Phys. Lett. 38(7) April 1, 1981, pp. 572-574.
	AC1	D.K. Flynn et al, "Deposition of Refractory Metal Films by Rare-Gas Halide Laser Photodissociation of Metal Carbonyls", J. Appl. Phys. 59 (11), 1 June 1986, pp. 3914-3917.
	AC2	S.A. Trushin et al., "Femtosecond Dynamics and Vibrational Coherence in Gas-Phase Ultraviolet Photodecomposition of CR(CO) ₆ ", J. Phys. Chem. A 1998, 102, pp. 4129-4137.
	AC3	R. Alexandrescu, "Laser-Stimulated Processes in Metal Carbonyls for Metal-Based Film Synthesis", Applied surface Science 106 (1996) pp. 28-37.
	AC4	H.H. Gilgen et al., "Direct Writing of Metal Conductors with Near -uv Light", Appl. Phys. B 42, 55-66 (1987), pp. 55-66.

Examiner:

Date Considered:

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.